See discussions, stats, and author profiles for this publication at: https://www.researchgate.net/publication/229090879

Atomistic Simulations of Self-Trapped Exciton Formation in Silicon Nanostructures: The Transition from Quantum Dots to Nanowires

ARTICLE in THE JOURNAL OF PHYSICAL CHEMISTRY C · JULY 2009

Impact Factor: 4.77 · DOI: 10.1021/jp903898u

CITATIONS

18

READS

37

4 AUTHORS:



Yong Wang

The University of Hong Kong

14 PUBLICATIONS 144 CITATIONS

SEE PROFILE



Rui Qin Zhang

City University of Hong Kong

326 PUBLICATIONS 5,690 CITATIONS

SEE PROFILE



Thomas Frauenheim

Universität Bremen

368 PUBLICATIONS 12,392 CITATIONS

SEE PROFILE



Thomas A. Niehaus

Claude Bernard University Lyon 1

89 PUBLICATIONS 1,682 CITATIONS

SEE PROFILE



2009, *113*, 12935–12938 Published on Web 07/01/2009

Atomistic Simulations of Self-Trapped Exciton Formation in Silicon Nanostructures: The Transition from Quantum Dots to Nanowires

Yong Wang, †,‡ Ruiqin Zhang,§ Thomas Frauenheim,† and Thomas A. Niehaus*,†

Bremen Center for Computational Materials Science, University of Bremen, 28359 Bremen, Germany, Institute of Physics, Chinese Academy of Sciences, P.O. Box 603, Beijing, 100190 China, and Centre of Super-Diamond and Advanced Films (COSDAF) and Department of Physics and Materials Science, City University of Hong Kong, Hong Kong SAR, China

Received: April 28, 2009; Revised Manuscript Received: June 11, 2009

Using an approximate time-dependent density functional theory method, we calculate the absorption and luminescence spectra for hydrogen passivated silicon nanoscale structures with large aspect ratio. The effect of electron confinement in axial and radial directions is systematically investigated. Excited state relaxation leads to significant Stokes shifts for short nanorods with lengths less than 2 nm but has little effect on the luminescence intensity. The formation of self-trapped excitons is likewise observed for short nanostructures only; longer wires exhibit fully delocalized excitons with negligible geometrical distortion at the excited state minimum.

1. Introduction

Research on silicon nanowires (SiNW) has intensified in the past years, owing to their potential applications in future nanotechnologies, such as nanosensors, nanoscale electronics, and photonics devices. This interest results from the electronic structure of SiNW being critically dependent on the size, orientation, passivation and doping level of the nanostructure. For example, it has been shown experimentally that the band gap can be tuned by choosing different growth directions and diameters for the wire. On the theoretical side, the ground state electronic structure and transport properties of different kinds of SiNW have been investigated by several authors.

Light absorption and emission of these systems have also attracted great attention, because the band gap in bulk crystalline Si is small and indirect, whereas that in SiNW can become large and direct due to the quantum confinement effect.^{13–17} This experimental progress paves the way to obtain visible light from silicon materials, and provides for the possibility of future optoelectronics applications. In the past, theoretical descriptions of the optical properties of SiNW were mainly restricted to determining their absorption spectrum.^{6,10,11} To quantify luminescence, it is often tacitly assumed that de-excitation occurs resonantly. However, absorption and emission spectra can differ considerably due to excited state relaxation, and simulations that take this Stokes shift into account are currently missing for SiNW.

2. Method and Simulation Approach

In this letter, we use the time-dependent density-functional based tight-binding (TD-DFTB) method¹⁸ (for a recent review

see ref 19), to study the excited states and optical properties of SiNW. The same method has been applied to silicon quantum dots, $^{20-26}$ where it was found to provide a high degree of reliability and computational efficiency compared with the parental time-dependent density functional theory (TD-DFT) from which it is derived. For example, the optical gap of Si₅H₁₂ is predicted to be 6.40 eV, in very good agreement with the experimental value of 6.50 eV.²⁷ Also for larger clusters like Si₃₅H₃₆, the TD-DFTB estimate for the lowest allowed singlet transition (4.37 eV) coincides with high level ab initio results from multireference second order perturbation theory (4.33 eV).²⁸

In principle, SiNW should be treated as quasi one-dimensional periodic systems, since their lengths are generally in the micrometer range while their diameters are several nanometers only. However, the TD-DFTB method we use here is currently restricted to deal with finite systems, thus, we construct silicon nanostructures along the (110) direction with increasing length to approach the experimentally realized SiNW. This allows us to demonstrate how the localized excitons in silicon quantum dots evolve into delocalized ones as the length of the Si nanostructures continuously increases. Focusing on finite structures also guarantees that we do not leave the trust region of TD-DFT. For periodic systems, local or semilocal approximations to the exchange-correlation functional lead to a collapse of the many-body excited state energies on the ground state Kohn-Sham gap.^{29,30} A better description of the electron-hole interaction is provided by quasi-particle calculations at the GW level combined with the solution of the Bethe-Salpeter equation. 31,32 For the confined systems discussed here, however, TD-DFT provides a reliable and affordable way to investigate optical properties.

We studied $\langle 110 \rangle$ SiNW with four different diameters, as shown in Figure 1. The diameters d are estimated to be 0.84, 0.98, 1.08, and 1.24 nm. Due to the limitation of computational

^{*} To whom correspondence should be addressed.

[†] Bremen Center for Computational Material Science.

[‡] Chinese Academy of Science.

[§] City University of Hong Kong.

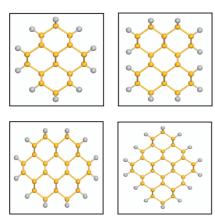


Figure 1. Ball and stick models of four $\langle 110 \rangle$ silicon nanowires (SiNW) with different diameters viewed from the top. Here Si atoms are yellow and H atoms are gray.

resources, SiNW with other growth directions or larger diameters were not considered. The simulation protocol for each structure can be summarized as follows: First, to build the structural model, we fully saturated the dangling bonds of surface Si atoms with hydrogen atoms. Second, the constructed models were relaxed in the ground state by conjugate gradient optimization using the DFTB method.³³ Third, we obtained the low energy part of the absorption spectrum at the ground state optimum by solving for the energies and oscillator strengths for the lowest five singlet excitations. Fourth, assuming rapid internal conversion, (i.e., the validity of Kasha's rule), the emission energies are evaluated by geometry optimization in the first excited singlet state (S₁). For most systems studied here, this assumption does not represent an approximation, since the strongest absorbing state is actually the S_1 . In the optimization process, we took advantage of a recent implementation of analytical excited state forces for the TD-DFTB scheme.³⁴ In all calculations the basis set consists of s and p orbitals for Si atoms and an s orbital for H atoms, and the gradient-corrected PBE exchange-correlation functional is employed.³⁵

For a given structure, excited state energies $(\omega_{\rm I})$ are obtained in two steps. ^{18,19} First, ground state spin-restricted DFTB calculations are performed to obtain the Kohn–Sham (KS) orbitals ψ_i and the KS energies ε_i . These single-particle values are corrected following the TD-DFT linear response treatment of Casida³⁶

$$\sum_{kl\tau} \left[\omega_{ij}^{2} \delta_{ik} \delta_{jl} \delta_{\sigma\tau} + 2\sqrt{\omega_{ij}} K_{ij\sigma,kl\tau} \sqrt{\omega_{kl}} \right] F_{kl\tau}^{I} = \omega_{1}^{2} F_{ij\sigma}^{I}$$
(1)

where $\omega_{ij} = \varepsilon_j - \varepsilon_i$ and σ and τ are spin indices. The coupling matrix $K_{ij\sigma,kl\tau}$ defined as³⁶

$$K_{ij\sigma,kl\tau} = \int \int \psi_i(\mathbf{r})\psi_j(\mathbf{r}) \left(\frac{1}{|\mathbf{r} - \mathbf{r'}|} + \frac{\delta^2 E_{xc}}{\delta \rho_o(\mathbf{r})\delta \rho_\tau(\mathbf{r'})} \right) \psi_k(\mathbf{r'})\psi_l(\mathbf{r'}) \, d\mathbf{r} \, d\mathbf{r'}$$

is further simplified in the TD-DFTB approach using the Mulliken approximation. ^{18,19}

With the results of eq 1, oscillator strengths for singlet-singlet transitions are calculated as³⁶

$$f_{\rm I} = \frac{2}{3} \omega_{\rm I} \sum_{k=x,y,z} \left| \sum_{ij} \langle \psi_i | \mathbf{r}_k | \psi_j \rangle \sqrt{\frac{\omega_{ij}}{\omega_{\rm I}}} (F_{ij\dagger}^{\rm I} + F_{ij\dagger}^{\rm I}) \right|^2 \quad (2)$$

3. Results and Discussion

In Figure 2, we show the absorption and luminescence spectra for the thinnest $\langle 110 \rangle$ nanowire (d=0.84 nm) with different lengths, from l=2.7 nm ($\mathrm{Si_{112}H_{98}}$) to l=4.2 nm ($\mathrm{Si_{176}H_{146}}$). Similar to what we have previously observed in silicon quantum dots with increasing diameter, ^{20,21} we find here that both absorption and emission energies slightly red-shift with increasing wire length. Moreover, a sizable Stokes shift of around 0.1-0.2 eV is discernible. Since excited state relaxation does not lead to a significant change in oscillator strengths, all considered nanostructures should exhibit significant luminescence intensity.

Next, we extracted the energies of the first allowed transition for SiNW with different diameters to investigate the size dependence of the optical gap (see Figure 3). When the length of the Si nanostructures increases from 0.39 to 2.73 nm, the absorption energies $E_{\rm abs}$ will decrease monotonously from around 5 eV to around 3 eV. This is due to the decrease of quantum confinement effects. Concurrently, the emission energies E_{emi} show an overall increase (although with some fluctuations for most cases) from 1 eV to around 3 eV and then follow the trend of the absorption energies. This general behavior, i.e., Stokes shifts that are large for small particles and tend to zero for infinite extension, has also been found in similar theoretical studies of the optical gap in spherical Si quantum dots.^{20,21} Quantum confinement effects are also observed in the radial dimension. Considering a fixed length of l = 1.56 nm, the optical gap decreases from 3.66 eV for the thinnest diameter (d = 0.84 nm) to 3.21 eV for d = 1.24 nm.

In order to understand the transition from quantum dots to wires more deeply, we analyze the geometrical distortions arising from the excited state relaxation. In small quantum dots, one Si-Si bond is extremely stretched up to 2.70 Å.²¹ Depending on the actual structure, the location of this bond can be either in the center of the cluster or at its surface. When the rods are long enough, the geometry distortions are small and more homogeneously distributed over all bonds. For the thinnest nanostructures (d = 0.84 nm), the distortions locate at one Si-Si bond in the center of the structures for lengths less than 1.95 nm and delocalize beyond this value, owing to the confinement provided by the rigid surrounding layer.²¹ For a diameter of 1.08 nm, geometry changes are observed for one Si-Si bond at the surface of the structures up to a length of 1.17 nm $(Si_{72}H_{68})$. The situation for the other two cases (d = 0.98 and 1.24 nm) is more involved. For the wire with d = 0.98 nm, distortions are found primarily for a Si-Si bond at the center of the quantum dots below 0.78 nm (Si₄₀H₄₈). The distortion is then delocalized for the cluster Si₆₀H₆₄ at 1.17 nm, which corresponds to the peak in the emission energy curve in Figure 3. It should be mentioned here that our simulation protocol locates the local minimum closest to the Franck-Condon point, i.e. the initial structure after light absorption. It cannot be ruled out that the global minimum of the S_1 potential energy surface is again of localized nature. Whether luminescence occurs also from this state will crucially depend on the excited state lifetime and the kinetic energy of the ions after absorption. Excited state molecular dynamics simulations could shed light on this interesting question, which is however outside the scope of this study.

Turning back to the results, a surface Si-Si bond is found to be elongated for the cluster $Si_{80}H_{80}$ at 1.56 nm and thereafter

Letters

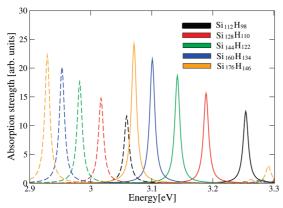


Figure 2. Absorption (solid lines) and emission spectra (dashed lines) for (110) nanowires with diameter 0.84 nm and different lengths (from 2.7 to 4.3 nm). The spectra have been broadened by 0.01 eV to simulate finite temperature.

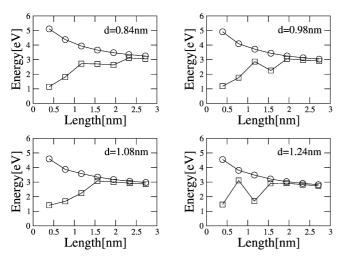


Figure 3. TD-DFTB absorption energies (circles) and emission energies (squares) for (110) SiNW with different diameter and lengths.

all distortions have a delocalized character for longer structures. A similar case are the wires with d = 1.24 nm, where a delocalized distortion appears for $Si_{60}H_{60}$ (l=0.78 nm), and a localized distortion for (l = 1.16 nm).

Additional information on the electronic structure can be extracted from the KS molecular orbitals that are involved in the light absorption and emission.³⁷ We take the rods $Si_{48}H_{50}$ (*l* = 1.17 nm) and $Si_{96}H_{86}$ (l = 2.32 nm) with diameter d = 0.84as examples. In both systems, the S_1 excited state wave function is dominated by a single-particle transitions from the highest occupied molecular orbital (HOMO) to the lowest unoccupied molecular orbital (LUMO). In Figure 4, these orbitals are depicted for the optimized geometries in S_0 and S_1 . We find for the ground state minimum of both structures that the HOMO distributes mainly along the central zone of the wire, while the LUMO is located on the surface. The molecular orbitals at the excited state minimum conformation are quite different for the two structures under investigation. The shorter structure, Si₄₈H₅₀, exhibits a LUMO concentrated at the center of the cluster that gives rise to a repulsive force. The significant Si-Si bond stretch in combination with the resulting sizable Stokes shift is completely in line with the self-trapped exciton model of Allan, Delerue, and Lannoo. 38,39 In contrast, the LUMO of the longer rod, Si₉₆H₈₆, distributes more or less homogeneously along the structure, indicating a delocalized exciton and geometry distortion.

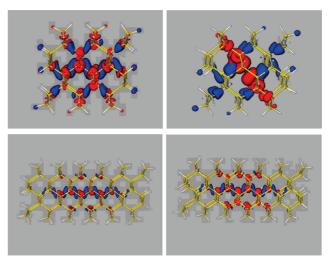


Figure 4. (color online) Absolute values of the molecular orbitals HOMO (blue) and LUMO (red) for ground state optimized (left) and excited state optimized (right) structures of Si₄₈H₅₀ (up) and Si₉₆H₈₆ (down), which are models of $\langle 110 \rangle$ SiNW with diameter d = 0.84 nm. The plot corresponds to an isovalue of 0.001.

4. Concluding Remarks

In conclusion, we simulated the absorption and emission spectra of SiNW with different diameters. The evolution of the optical properties from small quantum dots to nanowires with large aspect ratio has been investigated. While short nanorods with lengths below 2 nm show localized excitations and the formation of self-trapped excitons, excited state relaxation has little effect on longer structures which exhibit delocalized excited states. Notwithstanding these general trends, silicon nanostructures with similar extensions can exhibit quite different localization characteristics conjoined with largely differing emission profiles. This fact may partially explain the reported spread of photoluminescence energies⁴⁰ and calls for atomistic simulations of these systems which take this strong conformation dependence into account.

Acknowledgment. The work described in this paper is supported by MOST of China [Project No. 2006CB933000] and the Research Grants Council of Hong Kong SAR [Project No. CityU 103907]. Y.W. thanks Dr. Xian Wang and Dr. Binghai Yan for useful discussions.

References and Notes

- (1) Cui, Y.; Wei, Q. Q.; Park, H. K.; Liber, C. M. Science 2001, 293, 1289.
 - (2) Cui, Y.; Lieber, C. M. Science 2001, 291, 851.
- (3) Gudiksen, M. S.; Lauhon, L. J.; Wang, J.; Smith, D. C.; Lieber, C. M. Nature 2002, 415, 617.
- (4) Duan, X. F.; Huang, Y.; Agarwal, R.; Lieber, C. M. Nature 2003, 421, 241.
- (5) Ma, D. D. D.; Lee, C. S.; Au, F. C. K.; Tong, S. Y.; Lee, S. T. Science 2003, 299, 1874.
- (6) Zhao, X. Y.; Wei, C. M.; Yang, L.; Chou, M. Y. Phys. Rev. Lett. 2004, 92, 236805
- (7) Zhang, R. Q.; Lifshitz, Y.; Ma, D. D. D.; Zhao, Y. L.; Frauenheim, T.; Lee, S. T.; Tong, S. J. Chem. Phys. 2005, 123, 144703.
- (8) Ponomareva, I.; Menon, M.; Srivastava, D.; Andriotis, A. N. Phys. Rev. Lett. 2005, 95, 265502.
- (9) Yan, B. H.; Zhou, G.; Duan, W. H.; Wu, J.; Gu, B.-L. Appl. Phys. Lett. 2006, 89, 023104.
- (10) Bruno, M.; Palummo, M.; Marini, A.; Del Sole, R.; Ossicini, S. Phys. Rev. Lett. 2007, 98, 036807.
- (11) Aradi, B.; Ramos, L. E.; Deák, P.; Köhler, T.; Bechstedt, F.; Zhang,
- Q.; Th, F. Phys. Rev. B 2007, 76, 113303. (12) Rurali, R.; Aradi, B.; Frauenheim, T.; Gali, A. Phys. Rev. B 2007,
- *76*, 113303.

- (13) Wolkin, M. V.; Jorne, J.; Fauchet, P. M. *Phys. Rev. Lett.* **1999**, 82, 197
- (14) Yu, D. P.; Bai, Z. G.; Wang, J. J.; Zou, Y. H.; Qian, W.; Fu, J. S.; Zhang, H. Z.; Ding, Y.; Xiong, G. C.; You, L. P.; Xu, J.; Feng, S. Q. *Phys. Rev. B* **1999**, *59*, R2498.
- (15) Li, C. P.; Sun, X. H.; Wong, N. B.; Lee, C. S.; Lee, S. T.; Teo, B. K. Chem. Phys. Lett. **2002**, 365, 22.
- (16) Lyons, D. M.; Ryan, K. M.; Morris, M. A.; Holmes, J. D. *Nano Lett.* **2002**, *2*, 811.
- (17) Guichard, A. R.; Barsic, D. N.; Sharma, S.; Kamins, T. I.; Brongersma, M. L. *Nano Lett.* **2006**, *6*, 2140.
- (18) Niehaus, T. A.; Suhai, S.; Della Sala, F.; Lugli, P.; Elstner, M.; Seifert, G.; Frauenheim, T. *Phys. Rev. B* **2001**, *63*, 085108.
- (19) Niehaus, T. A. J. Mol. Struct.: THEOCHEM 2009, doi: 10.1016/j.theochem.2009.04.034.
- (20) Wang, X.; Zhang, R. Q.; Niehaus, T. A.; Frauenheim, T.; Lee, S. T. J. Phys. Chem. C 2007, 111, 12588.
- J. Phys. Chem. C 2007, 111, 12588.
 (21) Wang, X.; Zhang, R. Q.; Lee, S. T.; Niehaus, T. A.; Frauenheim,
- (22) Li, Q.; Zhang, R. Q.; Niehaus, T. A.; Frauenheim, T.; Lee, S. T. Appl. Phys. Lett. 2007, 91, 043106.

T. Appl. Phys. Lett. 2007, 90, 123116.

- (23) Wang, X.; Zhang, R. Q.; Lee, S. T.; Frauenheim, T.; Niehaus, T. A. Appl. Phys. Lett. **2008**, *93*, 243120.
- (24) Li, Q. S.; Zhang, R. Q.; Lee, S. T.; Niehaus, T. A.; Frauenheim, T. Appl. Phys. Lett. **2008**, *92*, 053107.
- (25) Li, Q. S.; Zhang, R. Q.; Lee, S. T.; Niehaus, T. A.; Frauenheim, T. J. Chem. Phys. **2008**, 128, 244714.
- (26) Li, Q. S.; Zhang, R. Q.; Niehaus, T. A.; Frauenheim, T.; Lee, S. T. J. Chem. Theo. Comp. **2007**, *3*, 1518.

- (27) Féher, F. Molekülspektroskopische Untersuchungen auf dem Gebiet der Silane und der heterocyclischen Sulfane; Westdeutscher Verlag: Berlin, 1977.
 - (28) Zdetsis, A. D. Rev. Adv. Mater. Sci. 2006, 11, 56.
 - (29) Izmaylov, A.; Scuseria, G. J. Chem. Phys. 2008, 129, 34101-34101.
- (30) Botti, S.; Schindlmayr, A.; Del Sole, R.; Reining, L. Rep. Prog. Phys. **2007**, 70, 357–407.
 - (31) Onida, G.; Reining, L.; Rubio, A. Rev. Mod. Phys. 2002, 74, 601.
- (32) Ramos, L. E.; Paier, J.; Kresse, G.; Bechstedt, F. *Phys. Rev. B* **2008**, 78, 195423.
- (33) Elstner, M.; Porezag, D.; Jungnickel, G.; Elsner, J.; Haugk, M.; Frauenheim, T.; Suhai, S.; Seifert, G. *Phys. Rev. B* **1998**, *58*, 7260–7268.
- (34) Heringer, D.; Niehaus, T. A.; Wanko, M.; Frauenheim, T. J. Comput. Chem. 2007, 28, 2589–601.
- (35) The respective DFTB integral tables are available as set *pbc-0*-2 from www.dftb.org.
- (36) Casida, M. E. In *Recent Advances in Density Functional Methods, Part I*; Chong, D., Ed.; World Scientific: Singapore, 1995; Chapter Time-dependent Density Functional Response Theory for Molecules, pp 155–192.
- (37) Based on the eigenvectors of eq 1, it is possible to perform a qualitative decomposition of the excited state wave function in terms of singly excited Kohn-Sham determinants. Please see ref 36 for details.
- (38) Allan, G.; Delerue, C.; Lannoo, M. Phys. Rev. Lett. **1996**, 76, 2961–2964
- (39) For a recent review on excitons in nanoscale systems see also ref
- (40) Wilcoxon, J. P.; Samara, G. A.; Provencio, P. N. *Phys. Rev. B* **1999**, 60, 2704–2714.
 - (41) Scholes, G. D.; Rumbles, G. Nat. Mater. 2006, 5, 683.

JP903898U